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APPLICATION NO.	FILING DATE	FIRST NAMED INVENTOR	ATTORNEY DOCKET NO.	CONFIRMATION NO.	
09/835,643	04/17/2001	Kie Y. Ahn	M4065.0383/P383	4830	
24998 7	590 03/23/2005		EXAMINER		
	SHAPIRO MORIN & O	ANDUJAR, LEONARDO			
2101 L Street, Washington, D			ART UNIT PAPER NUMB		
			2826		
			DATE MAILED: 03/23/2005		

Please find below and/or attached an Office communication concerning this application or proceeding.

		Application No.	Applicant(s)	
Office Action Summany		09/835,643	AHN ET AL.	(Eu
	Office Action Summary	Examiner	Art Unit	
	The MAN INC DATE of this constitution	Leonardo Andújar	2826	
Period fo	The MAILING DATE of this communication ap or Reply	pears on the cover sheet with t	he correspondence addr	ess
THE - Exte after - If the - If NC - Failu - Any earne	ORTENED STATUTORY PERIOD FOR REPL MAILING DATE OF THIS COMMUNICATION. nsions of time may be available under the provisions of 37 CFR 1. SIX (6) MONTHS from the mailing date of this communication. e period for reply specified above is less than thirty (30) days, a reply period for reply is specified above, the maximum statutory period re to reply within the set or extended period for reply will, by statuting received by the Office later than three months after the mailing and patent term adjustment. See 37 CFR 1.704(b).	136(a). In no event, however, may a reply to the statutory minimum of thirty (30 will apply and will expire SIX (6) MONTHS e, cause the application to become ABAND	pe timely filed) days will be considered timely. from the mailing date of this comr ONED (35 U.S.C. § 133).	nunication.
Status	Decreasive to communication(s) find an OO	March 0005		
1)[\]	Responsive to communication(s) filed on <u>08</u>			
2a)☐	,—	nis action is non-final.		., .
3) 🗌	Since this application is in condition for allow closed in accordance with the practice under ion of Claims			merits is
·	Claim(s) <u>1,3-44 and 92-110</u> is/are pending in	the application		
	4a) Of the above claim(s) is/are withdra			
	Claim(s) <u>4-9,12-44 and 92-110</u> is/are allowed.			
·	Claim(s) 1,3,10 and 11 is/are rejected.			
·	Claim(s) is/are objected to.			
8)	Claim(s) are subject to restriction and/o	or election requirement.		
Applicat	ion Papers			
9)	The specification is objected to by the Examine	er.		
10) 🔲	The drawing(s) filed on is/are: a) \square acce	epted or b) objected to by the E	Examiner.	
	Applicant may not request that any objection to the	ne drawing(s) be held in abeyance	. See 37 CFR 1.85(a).	
11) 🔲	The proposed drawing correction filed on	_ is: a)□ approved b)□ disar	pproved by the Examiner.	
	If approved, corrected drawings are required in re	•		•
	The oath or declaration is objected to by the Ex	xaminer.		
Priority ι	under 35 U.S.C. §§ 119 and 120			
	Acknowledgment is made of a claim for foreig	n priority under 35 U.S.C. § 11	9(a)-(d) or (f).	
a)	☐ All b)☐ Some * c)☐ None of:	•		
	1. Certified copies of the priority document			
	2. Certified copies of the priority document	ts have been received in Appli	cation No	
* 5	3. Copies of the certified copies of the price application from the International Buse the attached detailed Office action for a list	ureau (PCT Rule 17.2(a)).		age
	Acknowledgment is made of a claim for domest			pplication).
) \square The translation of the foreign language process. Acknowledgment is made of a claim for domes			,
Attachmen		,, <u></u> 23		
2) Notic	ce of References Cited (PTO-892) se of Draftsperson's Patent Drawing Review (PTO-948) mation Disclosure Statement(s) (PTO-1449) Paper No(s) (5) Notice of Infor	mary (PTO-413) Paper No(s). nal Patent Application (PTO-	

DETAILED ACTION

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Continued Examination Under 37 CFR 1.114

1. A request for continued examination under 37 CFR 1.114, including the fee set forth in 37 CFR 1.17(e), was filed in this application after final rejection. Since this application is eligible for continued examination under 37 CFR 1.114, and the fee set forth in 37 CFR 1.17(e) has been timely paid, the finality of the previous Office action has been withdrawn pursuant to 37 CFR 1.114. Applicant's submission filed on 03/08/2005 has been entered.

Claim Rejections - 35 USC § 103

- 2. The following is a quotation of 35 U.S.C. 103(a) which forms the basis for all obviousness rejections set forth in this Office action:
 - (a) A patent may not be obtained though the invention is not identically disclosed or described as set forth in section 102 of this title, if the differences between the subject matter sought to be patented and the prior art are such that the subject matter as a whole would have been obvious at the time the invention was made to a person having ordinary skill in the art to which said subject matter pertains. Patentability shall not be negatived by the manner in which the invention was made.
- 3. Claims 1, 3 and 11 are rejected under 35 U.S.C. 103(a) as being unpatentable over Hu et al (cited by Applicant) in view of Solon Spiegel (cited by applicant)
- 4. Hu discloses a method of manufacturing a coplanar wave guide comprising the acts of: forming a signal conductor line over a substrate; forming two longitudinal ground conductor planes over the substrate and opposing sides of the signal conductor line, the ground conductor planes being spaced form the signal conductor line and subsequently forming a trench in the substrate in an area between at least one of the ground conductor planes and the signal conductor line (page 736, col. 1). Hu does not disclose

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the step of depositing an insulating material on the substrate and the step of forming the signal conductor line and the ground conductor planes on top of the insulating layer. Nevertheless, Spiegel teaches a method of forming a coplanar waveguide including the step of depositing an insulating material (e.g. silicon nitride or silicon oxide) on the substrate and the step of forming the signal conductor line and the ground conductor planes on top of the insulating layer. According to Spiegel, this type of embodiment increases the effective substrate conductivity, which provides a wide band microwave (page 1673; col. 2/lls. 38-46 and page 1677; col. 2/lls. 17-26). It would have been obvious to one of ordinary skill in the art at the time the invention was made to include the step of depositing an insulating material such as silicon oxide on the substrate disclosed by Hu and to form the signal conductor line and the ground conductor planes on top of the insulating layer as suggested by Spiegel to increase effective substrate conductivity and to provide a wide microwave band.

- 5. Regarding claim 11, Hu teaches the step of forming the conductive material layers of the waveguide by evaporation ((page 736, col. 1). Note that thermal evaporation is also known in the semiconductor art as evaporation, vapor deposition, sputtering, etc.
- 6. Claim 10 is rejected under 35 U.S.C. 103(a) as being unpatentable over Hu et al (cited by Applicant) in view of Solon Spiegel (cited by applicant) further in view of Tran (US 6,259,407 cited by Applicant).
- 7. Hu in view of Spiegel teaches most aspects of the instant invention except for a conductive material comprising copper. Nonetheless, Tran teaches a method for

making a coplanar waveguide including the use of copper for making the waveguide conductive layers (col. 7/lls. 55-60). It would have been obvious to one having ordinary skill in the art at the time the invention was made to use copper to make the conductive layers of the waveguide disclosed by Hu in view of Spiegel as suggested by Tran, since it has been held to be within the general skill of a worker in the art to select a known material on the basis of its suitability for the intended use as a matter of obvious design choice. *In re Leshin, 125 USPQ 416.*

Allowable Subject Matter

8. Claims 4-9, 12-44 and 92-110 are allowed.

Response to Arguments

9. Applicant's arguments with respect to claim 1 have been considered but are moot in view of the new ground(s) of rejection.

Conclusion

- 10. Any inquiry concerning this communication or earlier communications from the examiner should be directed to Leonardo Andújar whose telephone number is 571-272-1912. The examiner can normally be reached on Mon through Thu from 9:00 AM to 7:30 PM EST.
- 11. If attempts to reach the examiner by telephone are unsuccessful, the examiner's supervisor, Nathan J. Flynn can be reached on 571-272-1915. The fax phone number for the organization where this application or proceeding is assigned is 703-872-9306.
- 12. Information regarding the status of an application may be obtained from the Patent Application Information Retrieval (PAIR) system. Status information for

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published applications may be obtained from either Private PAIR or Public PAIR. Status information for unpublished applications is available through Private PAIR only. For more information about the PAIR system, see http://pair-direct.uspto.gov. Should you have questions on access to the Private PAIR system, contact the Electronic Business Center (EBC) at 866-217-9197 (toll-free).

Leonardo Andújar

Patent Examine Art Unit 2826

LA 03/15/2005